	Application No.	Applicant(s)
Notice of Allowability	10/005,240	WHILTON
	Examiner	Art Unit
	Charles I. Boyer	1751
The MAILING DATE of this communication appearable seriously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGOR THE OF THE O	(OR REMAINS) CLOSED in this app or other appropriate communication GHTS. This application is subject to	olication. If not included will be mailed in due course. THIS
1. X This communication is responsive to applicants' response r	received June 21, 2005.	
2. ☑ The allowed claim(s) is/are <u>1-13 and 15-17</u> .		
3. The drawings filed on are accepted by the Examiner	·.	
4.	been received. been received in Application No cuments have been received in this is of this communication to file a reply of this application. Itted. Note the attached EXAMINER' as reason(s) why the oath or declarate to be submitted. on's Patent Drawing Review (PTO- as Amendment / Comment or in the Octobre Same Amendment of the drawing to 37 CFR 1.121(content of the Content of the Con	national stage application from the complying with the requirements S AMENDMENT or NOTICE OF tion is deficient. 948) attached office action of the back) of the complying with the front (not the back) of the complying and the submitted. Note the
attached Examiner's comment regarding REQUIREMENT F		
1. ☐ Notice of References Cited (PTO-892)		atent Application (PTO-152)
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. ☐ Interview Summary Paper No./Mail Dat	
Information Disclosure Statements (PTO-1449 or PTO/SB/08 Paper No./Mail Date	8), 7. 🛛 Examiner's Amendn	nent/Comment
4. Examiner's Comment Regarding Requirement for Deposit	<u> </u>	ent of Reasons for Allowance
of Biological Material	9. Other	
,	CHAPLES BOYER PRIMARY EXAMINER	0
·	Chall.	Dozel

EXAMINER'S AMENDMENT

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

The application has been amended as follows:

In line 1 of claim 15, delete "Use according to claim 14" and insert –The method of claim 16—

Allowable Subject Matter

1. The following is an examiner's statement of reasons for allowance: Applicants have claimed a fabric treatment composition comprising a textile compatible carrier and water insoluble particles having a layered structure comprising oxygen atoms and silicon and/or phosphorus atoms, and comprising organic functional groups which are bonded to silicon and/or phosphorus atoms in the layers by direct covalent bonds between the silicon and/or phosphorus atoms and a carbon atom.

The closest prior art of Hanauer et al, US 4,742,039 teaches adsorbents based on organophyllosilicates that are suitable as additives for enhancing the washing action in detergents (see abstract). Applicants have stated for the roord that this reference does not satisfy the claim limitations for the reasons set forth below:

Hanauer et al (US 4.742,039) discloses organophillic phyllosilicates (and not

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organophyllosllicates) that are organo clay particles in which the organic species (ammonium quat) sits in the interstitial spaces between the layers of the clay. Hanauer describes that this is achieved by ion exchange, in which the charge balancing hydrogen or metal cations initially present are preferentially exchanged for the charged ammonium compounds (column 4, lines 51-55, column 3, lines 48-50). That these cations are extraneous, and therefore not an integral part of the framework of the clay is disclosed at column 3, lines 45-48. Both natural and synthetic clays are disclosed, and while a synthesis of synthetic clays is described, the person skilled in the art is taught away from introducing organic species during the synthesis, see column 3, lines 53-55. Even if the skilled person did try out the process referred to at column 3, line 52 and described in detail at column 3, line 56 to column 4, line 33, "in the presence of small amounts of organic compounds" (column 3, lines 52-55), the organo clay resulting would only contain the organic compounds in the interstitial spaces, and not covalently bound to inorganic groups of the clay (as required by the present invention). Nowhere is a clay containing direct covalent bonds between the organic groups and the Si or P groups of the clay disclosed, only electrostatic bonds between the charged clay layer surface and the charged organic compound.

In light of these arguments, the rejection is withdrawn, and as no other prior art rejections remain, the present claims are allowable.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably Application/Control Number: 10/005,240

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accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Charles I. Boyer whose telephone number is 571 272 1311. The examiner can normally be reached on M-F 9:30 to 6:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Yogendra Gupta can be reached on 571 272 1316. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

> Charles I Bover Primary Examiner Art Unit 1751